

WEST Search History

DATE: Thursday, June 19, 2003

Set Name Query

side by side

Hit Count Set Name

result set

DB=JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ

L39	(ALD or ALE or (atomic layer (deposit\$4 or epitax\$7)) or \$4CVD or (vapor near2 deposit\$3)) and ((wall near3 temperature) and ((adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) and (decomposit\$7)))	1	L39
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DB=USPT,PGPB; PLUR=YES; OP=ADJ

L38	L37 not (L33 or L34)	5	L38
L37	(ALD or ALE or (atomic layer (deposit\$4 or epitax\$7)) or \$4CVD or (vapor near2 deposit\$3)) and ((wall near3 temperature) same ((adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	13	L37

DB=JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ

L36	(ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((wall near3 temperature) same ((prevent\$3 or reduc\$6 or eliminat\$6 or minimiz\$6 or decreas\$5) with (adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	0	L36
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DB=USPT,PGPB; PLUR=YES; OP=ADJ

L35	(ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((wall near3 temperature) same ((prevent\$3 or reduc\$6 or eliminat\$6 or minimiz\$6 or decreas\$5) with (adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	1	L35
L34	L33 not L32	3	L34
L33	(\$4CVD or (vapor near2 deposit\$3)) and ((wall near3 temperature) same ((prevent\$3 or reduc\$6 or eliminat\$6 or minimiz\$6 or decreas\$5) with (adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	8	L33
L32	L7 and ((wall near3 temperature) same ((prevent\$3 or reduc\$6 or eliminat\$6 or minimiz\$6 or decreas\$5) with (adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) with (decomposit\$7)))	5	L32

DB=JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ

L31	(substrate near2 temperature) and (wall near2 temperature) and (ALD or ALE or (atomic layer (deposit\$4 or epitax\$7)))	1	L31
L30	((substrate near2 temperature) same (control\$4 or adjust\$3 or regulat\$5 or alter\$3 or maintain\$3 or independent\$4 or separat\$5 or seperat\$5 or differ\$4 or higher or lower or hot or hotter or cold or colder or cool or cooler) same (wall near2 temperature))	36	L30
L29	L28 not L27	23	L29
	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or		

L28	condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (chamber or wall or reactor or vessel or vessell) with (prevent\$6 or unwant\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	27	L28
L27	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3 or adjust\$4 or maintain\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	7	L27
<i>DB=USPT,PGPB; PLUR=YES; OP=ADJ</i>			
L26	L25 and (ALD or ALE or (atomic layer (deposit\$4 or epitax\$7)))	0	L26
L25	L24 not (L12 or L13 or L14) ((substrate near2 temperature) with (control\$4 or adjust\$3 or regulat\$5 or alter\$3 or maintain\$3 or independent\$4 or separat\$5 or seperat\$5 or differ\$4 or higher or lower or hot or hotter or cold or colder or cool or cooler) with (wall near2 temperature))	40	L25
L24		64	L24
L23	L22 not (L21 or L11)	31	L23
L22	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (wall) with (prevent\$6 or unwanted\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	55	L22
L21	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and (((adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7) and (decompos\$8)) near8 (chamber or wall or reactor or vessel or vessell) with (prevent\$6 or unwanted\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	7	L21
L20	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (chamber or wall or reactor or vessel or vessell) with (prevent\$6 or unwant\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	299	L20
L19	L18 not L8	66	L19
L18	((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3 or adjust\$4 or maintain\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	88	L18
L17	L16 not L11	15	L17
L16	L7 and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (wall)))	48	L16
L15	L14 not (L12 or L13)	13	L15
L14	L7 and ((substrate near2 temperature) with (control\$4 or adjust\$3 or regulat\$5 or alter\$3 or maintain\$3) with (wall near2 temperature))	16	L14

L13	L7 and ((substrate near2 temperature) with (independent\$3 or separat\$4 or separat\$4) with (wall near2 temperature))	3	L13
L12	L7 and ((substrate near2 temperature) with (differ\$4 or higher or lower or hot or hotter or cool or cooler or cold or colder) with (wall near2 temperature))	9	L12
L11	L7 and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (chamber or wall or reactor or vessel or vessell) with (prevent\$6 or unwanted\$3 or undesir\$6 or (un want\$3) or (un desir\$6) or eliminat\$5 or reduc\$5 or temperature or heat\$3 or cool\$3)))	89	L11
L10	L7 and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((coat\$3 or deposit\$3 or film or layer or grow\$3 or adsorb\$5 or condens\$6 or adsorp\$5 or physisor\$7 or decompos\$8) near3 (chamber or wall or reactor or vessel or vessell)))	160	L10
L9	L8 not (L1 or L2)	18	L9
L8	L7 and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	22	L8
L7	L4 or L5 or L6	8243	L7
L6	(118/724).ccls. or ((118/725)!.CCLS.)	2341	L6
L5	(118/715).ccls. or (118/719).ccls. or ((118/728)!.CCLS.)	3889	L5
L4	(427/248.1).ccls. or (427/255.23).ccls. or (427/255.28).ccls. or (427/255.7).ccls. or (427/587).ccls. or (117/84).ccls. or (117/88).ccls. or (117/105).ccls. or ((117/85)!.CCLS.)	3533	L4
<i>DB=JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>			
L3	(Bondestam or Lindfors or ASM) and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	1	L3
<i>DB=USPT,PGPB; PLUR=YES; OP=ADJ</i>			
L2	(Bondestam.in. or Lindfors.in. or ASM.as.) and ((ALD or ALE or (atomic layer (deposit\$4 or epitax\$7))) and ((control\$3 or regulat\$3 or differ\$4 or higher or lower or increas\$3 or decreas\$3) with (substrate) with (chamber or wall or reactor or vessel or vessell) with (temperature)))	4	L2
L1	6579374.pn. or 6562140.pn.	2	L1

END OF SEARCH HISTORY